CLAIMS



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- 1. A semiconductor device comprising:
 - a first lead having an inner portion;
- a semiconductor chip mounted on the inner portion of the first lead;
- a second lead having an inner portion electrically connected to the semiconductor chip; and
- a resin package for sealing the semiconductor chip
 together with the inner portions of the first and second leads;

wherein at least the semiconductor chip is coated with a coating film formed of amorphous fluororesin.

- 2. The semiconductor device according to claim 1, wherein the semiconductor chip is electrically connected to the inner portion of the second lead via a wire, the coating film also covering the wire and the inner portions of the first and second leads.
- 3. The semiconductor device according to claim 1, wherein the amorphous fluororesin is PTFE.
 - 4. The semiconductor device according to claim 1, wherein the coating film has a thickness of 5-50 μm .

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5. The semiconductor device according to claim 1, wherein the semiconductor chip is an LED chip.

- 6. The semiconductor device according to claim 1, wherein the resin package is formed of a transparent resin.
- 7. A method of making a semiconductor device comprising the steps of:

mounting a semiconductor chip on an inner portion of a first lead;

electrically connecting the semiconductor chip to an inner portion of a second lead;

coating at least the semiconductor chip with a coating film formed of amorphous fluororesin; and

molding a resin package for sealing the semiconductor chip together with the inner portions of the first and second leads.

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- 8. The method according to claim 7, wherein the semiconductor chip is electrically connected to the inner portion of the second lead via a wire, the coating step is performed for causing the coating film to also cover the wire and the inner portions of the first and second leads.
- 9. The method according to claim 7, wherein the coating step is performed by using PTFE as the amorphous fluororesin.
- 10. The method according to claim 7, wherein the coating step is performed until the coating film grows to a thickness of $5-50\mu m$.

- 11. The method according to claim 7, wherein the coating step is performed by applying a amorphous fluororesin mixed with a volatile solvent and drying the same.
- 5 12. The method according to claim 7, wherein the molding step is performed by using a transparent resin.